

APPLICATION DATA SHEET

Application Information

Application Type::	Continuation
Subject Matter::	Utility
Title::	Method of Manufacturing a Semiconductor Apparatus with a Tapered Aperture Pattern to Form a Predetermined Line Width
Attorney Docket Number::	09792909-5787
Request for Early Publication?::	No
Request for Non-Publication?::	No
Total Drawing Sheets::	2
Small Entity?::	No

Applicant Information

Applicant Authority Type::	Inventor
Primary Citizenship Country::	Japan
Status::	Full Capacity
Given Name::	Fumikatsu
Family Name::	Uesawa
City of Residence::	Kanagawa
Country of Residence::	Japan
Street of Mailing Address::	7-35, Kitashinagawa 6-chome, Shinagawa-ku
City of Mailing Address::	Tokyo
State or Province of Mailing Address::	
Address::	Japan
Postal Code of Mailing Address::	141

Correspondence Information

Correspondence Customer Number::	26263
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Representative Information

Representative Customer Number::	26263
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Priority Information

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This application is a	continuation of	10/154,237	05/23/2002
10/154,237	claims priority to	Japanese 2001-153326	05/23/2001

Assignee Information

Assignee Name::

Sony Corporation

23130893IV-1